Wafer

Wafer label

Standard Position A	90° Clockwise Position B	180° Clockwise Position C	270° Clockwise Position D

Figure 1

App No.:   09/871,610
Title: New Methods for Array Preparation.
Inventors: Glenn McGall, *et al.*

HuGen FL Rotation Exp O3MOS

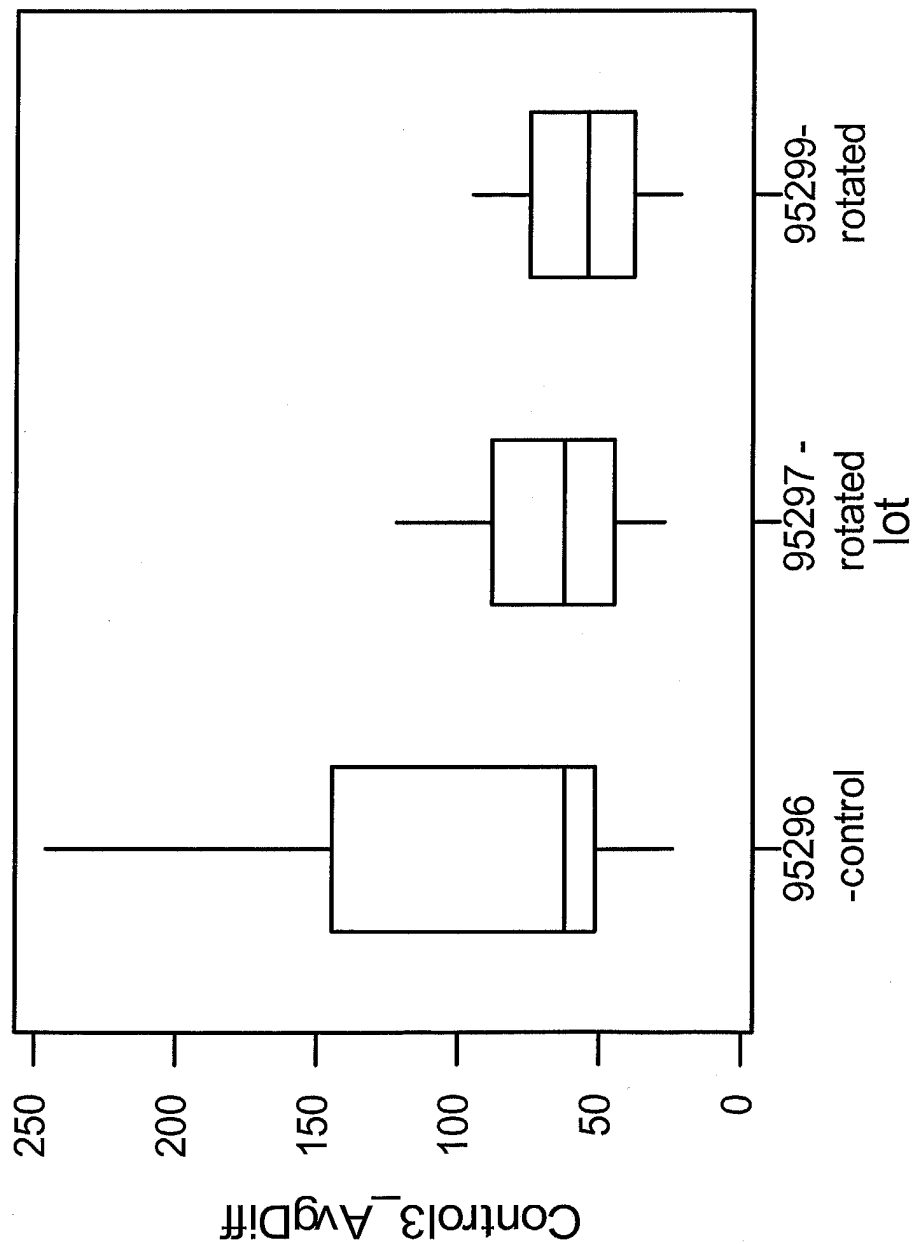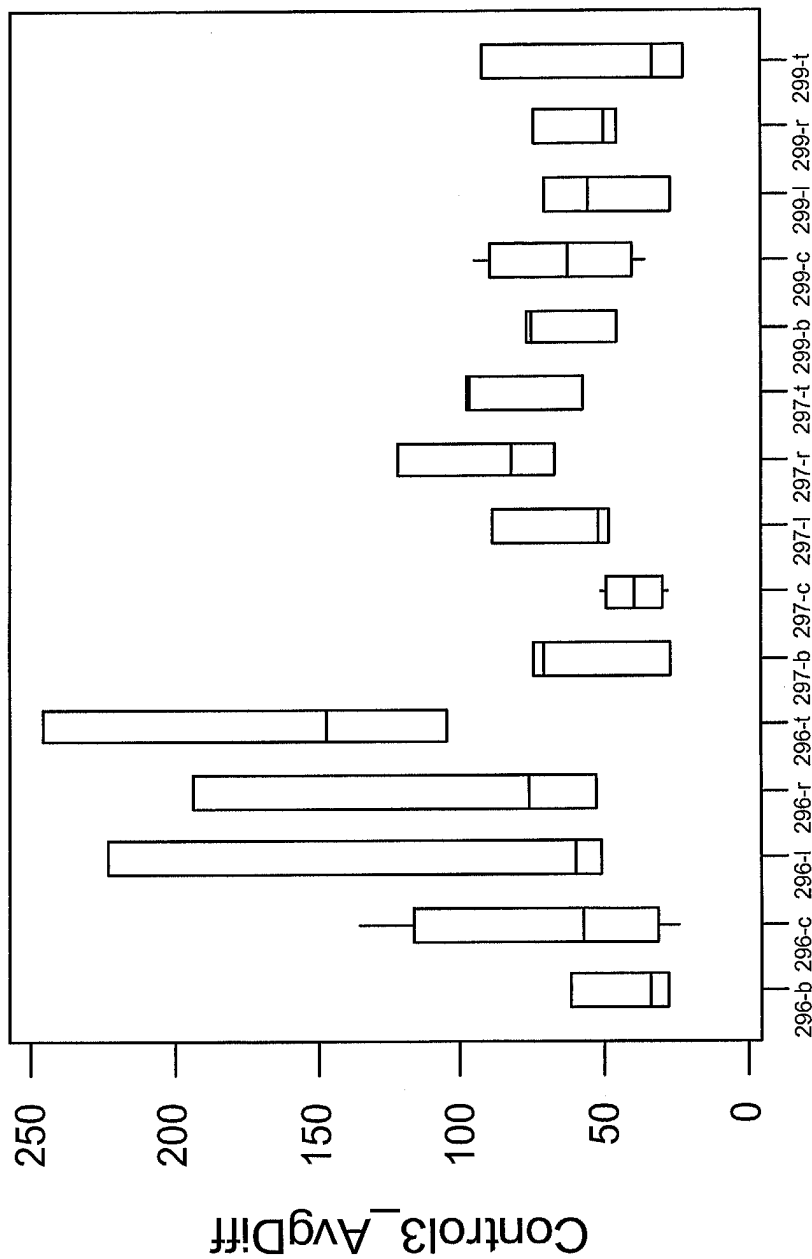Figure 2

HuFL - Rotation Exp O3MOS

Control3_AvgDiff

250   200   150   100   50   0

lot-zone

296-b 296-c 296-l 296-r 296-t 297-b 297-c 297-l 297-r 297-t 299-b 299-c 299-l 299-r 299-t

Figure 3